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## Solid-State Image Pickup Device

### BACKGROUND OF THE INVENTION

#### Field of the Invention

5           The present invention relates to a solid-state image pickup device such as a CCD or CMOS image sensor used in a digital camera or the like.

          Conventionally, a solid-state image pickup device such as a CCD or CMOS image sensor is utilized in a  
10       digital camera or the like and its application field expands. As the product becomes more downsized and lower-profile, a solid-state image pickup device which is more downsized and lower-profile is strongly demanded. In order to meet this demand, a solid-state  
15       image pickup device using a TAB (Tape-Automated Bonding) tape as described in, e.g., U.S.P. No. 5,506,401, is available.

          Fig. 7 is a sectional view of a solid-state image pickup device described in the above reference. As  
20       shown in Fig. 7, in a conventional solid-state image pickup device, a TAB tape 2 with an insulating film 22 and copper leads 21 is adhered to one surface of a protection cap 3 with an adhesive 10.

          The TAB tape 2 is connected onto bumps 6 formed on  
25       electrode pads 5 of a solid-state image element pickup chip 1, on which a plurality of solid-state image pickup elements 7 are mounted, through an anisotropic

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image pickup element chip expands by heating and escapes from the sealed structure. If encapsulation is completed in this state, air in the sealed structure that has been restored to room temperature shrinks, and a warp occurs in the solid-state image pickup element chip. As a countermeasure for this, a portion free from the sealing resin is reserved in advance so a vent hole is formed there after adhesion, and this portion is closed later on and encapsulation is completed. In this case, however, the process increases, leading to an increase in cost.

Shrinkage of the sealing resin itself during hardening also warps the solid-state image pickup element chip. When a warp occurs in the solid-state image pickup element chip in the above manner, the focal point differs among the pixels of the solid-state image pickup elements, and the image quality degrades.

#### SUMMARY OF THE INVENTION

It is, therefore, an object of the present invention to provide a solid-state image pickup device in which a warp does not occur in the solid-state image pickup element chip.

In order to achieve the above object, according to the present invention, there is provided a solid-state image pickup device comprising a solid-state image pickup element chip on which a plurality of solid-state

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image pickup elements are mounted, and a protection cap provided on a light incident side of the solid-state image pickup element chip and adapted to protect the solid-state image pickup element chip, characterized in that the solid-state image pickup element chip is formed on a substrate with a thermal expansion coefficient equal to that of the protection cap, and the substrate and the protection cap are sealed with a sealing resin.

10           According to the present invention, there is also provided a solid-state image pickup device comprising a solid-state image pickup element chip on which a plurality of solid-state image pickup elements are mounted, and a protection cap provided on a light incident side of the solid-state image pickup element chip and adapted to protect the solid-state image pickup element chip, characterized in that the solid-state image pickup element chip is formed on a substrate made of the same material as that of the protection cap through a light-shielding layer that shields light, and the substrate and the protection cap are sealed with a sealing resin.

25           More specifically, according to the present invention, the protection cap and solid-state image pickup element chip with different thermal expansion coefficients are not directly adhered to each other, so no warp is caused in the solid-state image pickup

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element chip by an ambient temperature change.

According to the present invention, the solid-state image pickup element chip is sealed between the protection cap and substrate, and is not fixed to the protection cap. Thus, even when the atmospheric pressure in the sealed structure changes or the sealing resin shrinks during hardening, no warp occurs in the solid-state image pickup elements.

10 BRIEF DESCRIPTION OF THE DRAWINGS

Fig. 1 is a sectional view of a solid-state image pickup device according to the first embodiment of the present invention;

Fig. 2 is a plan view of Fig. 1;

15 Fig. 3 is an exploded perspective view of Fig. 1;

Fig. 4 is a sectional view of a solid-state image pickup device according to the second embodiment of the present invention;

20 Fig. 5 is a sectional view of a solid-state image pickup device according to the third embodiment of the present invention;

Fig. 6 is a sectional view of a solid-state image pickup device according to the fourth embodiment of the present invention; and

25 Fig. 7 is a sectional view of a conventional solid-state image pickup device.

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## DESCRIPTION OF THE PREFERRED EMBODIMENTS

The preferred embodiments of the present invention will be described in detail with reference to the accompanying drawings.

### 5 (First Embodiment)

Fig. 1 is a sectional view of a solid-state image pickup device according to the first embodiment of the present invention. Fig. 2 is a plan view of Fig. 1. Fig. 3 is an exploded perspective view of Fig. 1.

10 Fig. 1 shows a state wherein a TAB tape 2 is connected to bumps 6 formed on electrode pads 5 of a solid-state image pickup element chip 1. The TAB tape 2 can be connected, e.g., by ultrasonic bonding or through an anisotropic conductive film or conductive paste.

15 To form the bumps 6, gold is usually used. Alternatively, the bumps 6 may be formed of another metal such as copper or nickel, or an alloy, and be plated with gold. In the TAB tape 2, a plurality of copper leads 21 are formed on an insulating film 22.  
20 The insulating film 22 is formed of a resin film such as a polyimide film.

A protection cap 3 is arranged on a light incident side of the solid-state image pickup element chip 1, and a substrate 4 is arranged on the lower surface of  
25 the solid-state image pickup element chip 1, such that they sandwich the solid-state image pickup element chip 1. The protection cap 3 is made of, e.g., non-alkali

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glass or quartz, and transmits light through it.  
Alternatively, a protection cap made of a resin having  
light transmission properties, e.g., an acrylic resin,  
may be used. An optical low-pass filter or infrared  
5 cutting filter may be formed on the protection cap 3.

Usually, a light-shielding film is formed on the  
periphery of the protection cap 3 so as to cover the  
bumps 6 and copper leads 21, so they will not cause  
diffused reflection of the incident light that  
10 adversely affects the image.

The substrate 4 has a thermal expansion  
coefficient equal to that of the protection cap 3, and  
is formed of, e.g., a glass substrate, ceramic  
substrate, metal substrate, or resin substrate, or by  
15 stacking them.

The protection cap 3 and substrate 4 are sealed at  
their peripheries with a sealing resin 8 to  
hermetically seal the solid-state image pickup element  
chip 1. For example, the sealing resin 8 is an epoxy-,  
20 acrylic, or phenol-based resin, and can be of either  
thermoset, ultraviolet-curing, or  
ultraviolet-curing/thermoset type. A filler may be  
mixed in the sealing resin 8 to improve the  
reliability. The filler may be either an inorganic or  
25 organic material, and is made of, e.g., silica.

According to this embodiment, since the protection  
cap 3 is adhered to the substrate 4 with a thermal

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expansion coefficient equal to that of the protection cap 3, a force that warps the solid-state image pickup element chip 1 is not substantially generated by an ambient temperature change. Since the solid-state image pickup element chip 1 is not directly influenced by a change in atmospheric pressure in the sealed structure or by shrinkage of the sealing resin 8 during hardening, a warp in the solid-state image pickup element chip 1 can be suppressed.

(Second Embodiment)

Fig. 4 is a sectional view of a solid-state image pickup device according to the second embodiment of the present invention. In Fig. 4, portions that are identical to those of Fig. 1 are denoted by the same reference numerals as in Fig. 1. Fig. 4 shows a state wherein a solid-state image pickup element chip 1 is fixed to a substrate 4 with a flexible adhesive 11.

For example, the adhesive 11 is made of an urethane-, silicone-, styrene-, ester-, vinyl chloride-, or epoxy-based resin, and preferably has a modulus of elasticity of 1,000 MPa or less. In this embodiment, the solid-state image pickup element chip 1 is fixed to a predetermined position of the substrate 4, so positioning which is necessary when attaching the solid-state image pickup device to a camera becomes easy. Also, since the adhesive 11 that fixes the solid-state image pickup element chip 1 has

flexibility, it does not cause a warp in the solid-state image pickup element chip 1.

(Third Embodiment)

Fig. 5 is a sectional view of a solid-state image pickup device according to the third embodiment of the present invention. In Fig. 5, portions that are identical to those of Fig. 1 are denoted by the same reference numerals as in Fig. 1. In Fig. 5, a glass substrate 12 made of the same material as that of a protection cap 3 is used. The glass substrate 12 has light transmission properties. Hence, a light-shielding film 13 is formed on the inner surface of the glass substrate 12 so unwanted light will not enter from the lower surface of the solid-state image pickup device.

The light-shielding film 13 is formed on the entire surface or only the periphery of the glass substrate 12 to surround a solid-state image pickup element chip 1. In this embodiment, since the protection cap 3 and glass substrate 12 are made of the same material, no warp is caused in the solid-state image pickup element chip 1 by a difference in thermal expansion coefficient. Since the light-shielding film 13 is formed on the glass substrate 12, incident light from the lower surface of the solid-state image pickup device can be prevented.

The light-shielding film 13, the glass substrate

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12, and the solid-state image pickup element chip 1 may be adhered to each other with an adhesive 11.

Alternatively, a flexible adhesive that can shield light may be used as the light-shielding film 13, and the glass substrate 12 and solid-state image pickup element chip 1 may be adhered to each other through the light-shielding adhesive. Alternatively, the light-shielding film 13 may be formed on the solid-state image pickup device shown in Fig. 4.

(Fourth Embodiment)

Fig. 6 is a sectional view of a solid-state image pickup device according to the fourth embodiment of the present invention. In Fig. 6, portions that are identical to those of Fig. 1 are denoted by the same reference numerals as in Fig. 1. In Fig. 6, a contact preventive member 14 is formed around a solid-state image pickup element chip 1 from a flexible resin.

For example, the contact preventive member 14 is formed by thermally bonding a thermoset resin, applied to a protection cap 3 in advance and rendered B-stage, to the solid-state image pickup element chip 1 and a substrate 4. The thermoset resin is rendered B-stage in order to prevent it from spreading to a light-receiving surface 7 during thermal bonding. In place of a thermoset resin, a thermoplastic resin may be used.

For example, the contact preventive member 14 is

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made of a flexible resin such as an urethane-,  
silicone-, styrene-, ester-, vinyl chloride-, epoxy-,  
or phenol-based resin, and preferably has a modulus of  
elasticity of 1,000 MPa or less. In this embodiment,  
5 the contact preventive member 14 is adhered to the  
periphery of the solid-state image pickup element chip  
1. Alternatively, the contact preventive member 14 may  
be formed outside the solid-state image pickup element  
chip 1, and be adhered to only the protection cap 3 and  
10 substrate 4.

In this embodiment, since the contact preventive  
member 14 is formed to surround solid-state image  
pickup elements 7, a sealing resin 8 does not enter the  
solid-state image pickup elements 7. Hence, the  
15 selection of the material of the sealing resin 8 is  
widened. Since the contact preventive member 14 is  
made of a flexible resin, no warp occurs in the  
solid-state image pickup element chip 1.

As has been described above, according to the  
20 present invention, a solid-state image pickup element  
chip is formed on a substrate with a thermal expansion  
coefficient equal to that of a protection cap, and the  
substrate and protection cap are sealed with a sealing  
resin. Alternatively, a solid-state image pickup  
25 element chip is formed on a substrate made of the same  
material as that of a protection cap through a  
light-shielding layer that shields light, and the

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substrate and protection cap are sealed with a sealing resin. Therefore, no warp occurs in the solid-state image pickup element chip.

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